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研究报告

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Research Report

April 22, 2024

Preemptive Shift in Venture Capital Investment: Beijing Vfortune New Energy Power Technology Development Co., Ltd.

Research Center for Sci-Tech and Finance

Abstract: Currently, China is implementing an innovation-driven development strategy, with scientific and technological innovation being a crucial factor in measuring the country's comprehensive strength. Promoting the transformation of scientific and technological achievements will strengthen the integration of science and technology with the economy, which is the key determinant of the success or failure of China's scientific and technological system reform.

Accompanied by ical systeical.-3(e)mation of scientific and technological achieveiments, relateid policies have been impleimented one after another. As market demand gradually increases, venture capital has begun to show a ' preemptive shift ' end. This report analyses ical34b)3(a)3(4k)3(g)3(ou)2(n)1(3)4(n)3(l)3
of Vfortuncal 310aNew[317E)3(n)3(ab)6(rg)6(y a)[310aP)3(w)3(e)[ )304T)3(e)4(c)3(h)3(n)3(o)4

participation in the investment and transformation of a semiconductor photoresist project. It was found that Vfortune New Energy, a venture capital institution established by a scientific and technological achievements platform company, has been successful in keeping up with the trend of venture capital investment. They have achieved this by making sustained capital investments, participating in project technology research and development, enhancing their patent layout, and developing project technology.

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Google Research

2020

1558

5.8

2.7%

2019

8 47

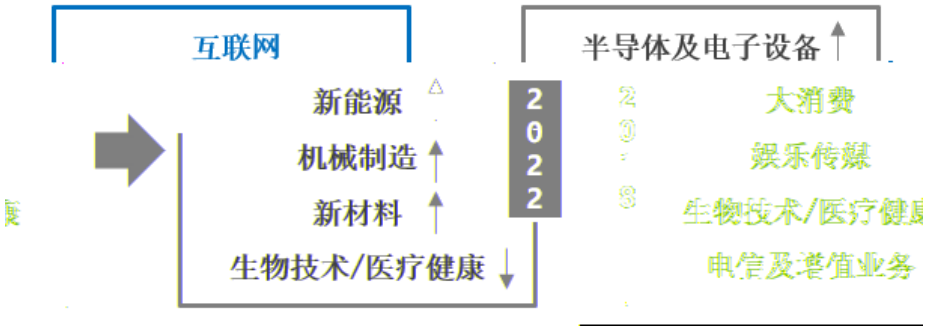
1273 32.4%

2019

34.8% 30

863 973

1


互联网
新能源
机械制造
新材料
生物技术/医疗健康
2022
半导体及电子设备
大消费
娱乐传媒
生物技术/医疗健康
电信及增值业务

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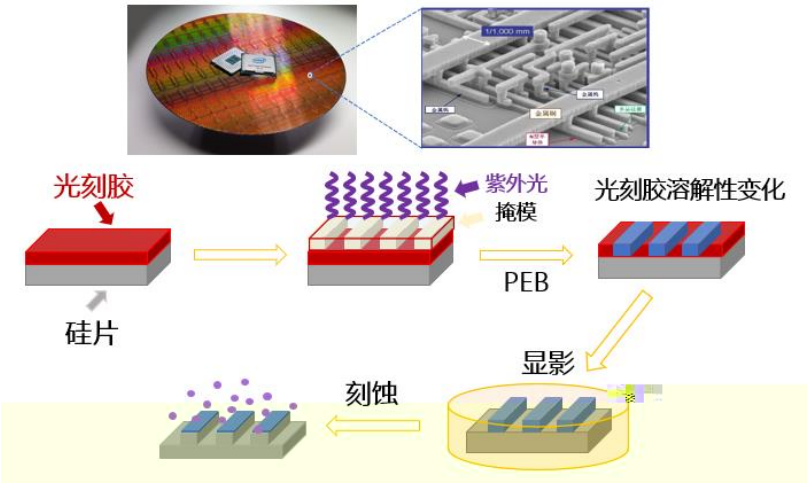

2

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2019

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2020 1 500 9

1000

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2020 12

2021 1

900

2020

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500

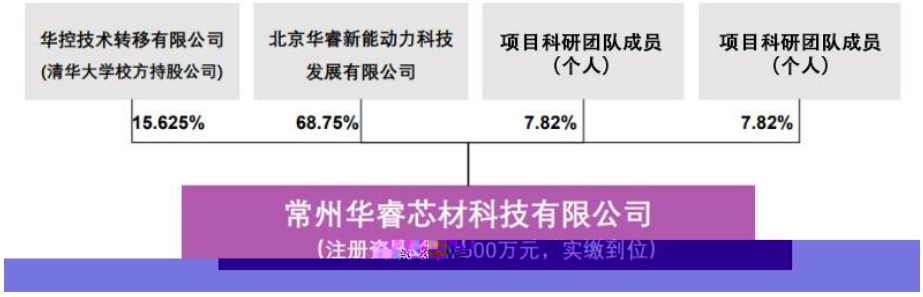
31.25%

2021 2

1600 1000 600

3

1



3

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2024

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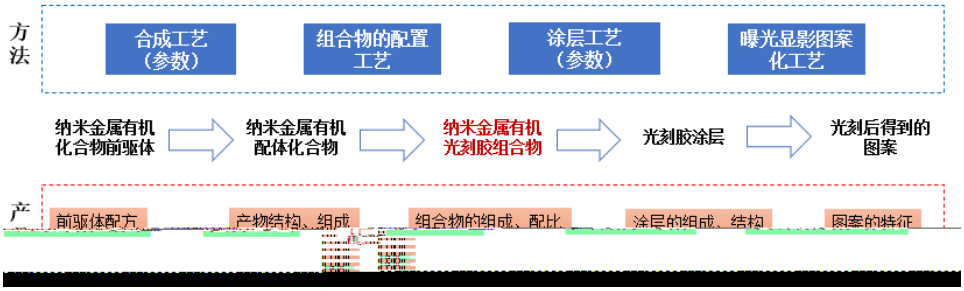
方法
合成工艺（参数）
组合物的配置工艺
涂层工艺（参数）
曝光显影图案化工艺
纳米金属有机化合物前驱体
纳米金属有机配体化合物
纳米金属有机光刻胶组合物
光刻胶涂层
光刻后得到的图案
产
前驱体配方
产物结构、组成
组合物的组成、配比
涂层的组成、结构
图案的特征

4

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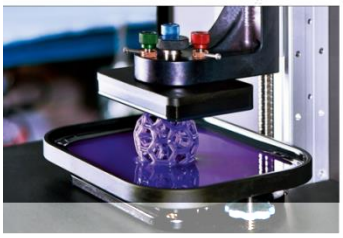
10000

双光子激光直写技术突破Rayleigh极限，直写速度提升100-1000倍

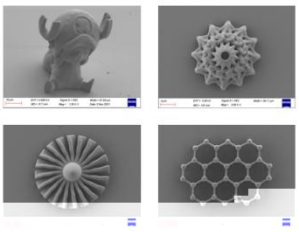
- 精度：50 ~ 200μm
  - 速度：10 ~ 150mm/s

- 精度：40 nm
  - 速度：7m/s



更小

更快



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M-10 3

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